

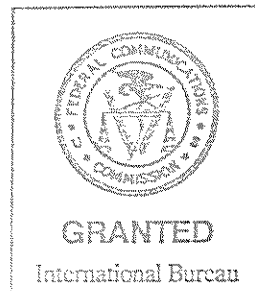
APPLICATION FOR EARTH STATION SPECIAL TEMPORARY AUTHORITY

APPLICANT INFORMATION Enter a description of this application to identify it on the main menu:
KVH Industries, Inc. ESV STA Application

I. Applicant

Name:	KVH Industries, Inc.	Phone Number:	401-845-8148
DBA Name:		Fax Number:	401-845-8116
Street:	50 Enterprise Center	E-Mail:	ffeingold@kvh.com
City:	Middletown	State:	RI
Country:	USA	Zipcode:	02842 -
Attention:	Ms Felise Feingold		

Conditions Attached



File # SES-STA-20081105-01449

Call Sign E090001 Grant Date 1/14/09
(or other identifier)

Term Dates
From 1/14/09 To: 3/14/09

Approved: J. L. Spriggs

KVH Industries, Inc.
Conditions to Grant
IBFS File No. SES-STA-20081105-01449

KVH Industries Inc. is granted Special Temporary Authority (STA) for a period of 60 days, from January 14, 2009, to March 14, 2009, to operate its Ku-Band ESV network (See IBFS File No. SES-LIC-20081104-01450) in accordance with its STA request, the Commission's rules, and the conditions set forth below.

1. The KVH Industries, Inc. ESV network shall operate in compliance with any pertinent limits established by the International Telecommunication Union (ITU) to protect other services allocated internationally.
2. KVH Industries, Inc. shall maintain a point of contact for discussing interference concerns with other licensees and U.S. Government agencies and shall submit a letter to be included in its license file with the name and telephone number of the contact prior to commencing operation.
3. All operating ESVs must be monitored, and operations adjusted if necessary, to ensure that no more interference in the geostationary plane is caused by the entire network of ESVs at any time (accumulating the interference caused by all correctly pointed and all mispointed ESV antennas) than would be caused by a single earth station transmitting in compliance with Sections 25.222(a)(1), 25.222(a)(3), and 25.222(a)(4) of the Commission's rules, using N=1.
4. Authority granted in this STA is without prejudice to the disposition of the underlying application in SES-LIC-20081104-01450.